Application No. 10/519,495 Art Unit 3732 Reply to Office Action of November 10, 2007

ABSTRACT

A method for treating an implant surface intended for implantation into bone wherein a microroughness having pores and peaks having a pore diameter of $\leq 1~\mu m$, a pore depth of ≤ 500 nm, and a peak width, at half the pore depth, of from 15 to 150% of the pore diameter is provided. Also provided is an implant having a surface with the above characteristics.